

B.Sc. ELECTRONICS
First Semester
BASIC ELECTRONICS
(BSE - 103)

Duration: 3Hrs.

Full Marks: 70

Part-A (Objective) =20
Part-B (Descriptive) =50

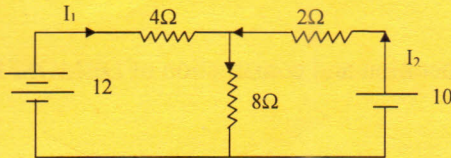
(PART-B: Descriptive)

Duration: 2 hrs. 40 mins.

Marks: 50

Answer any five of the following questions:

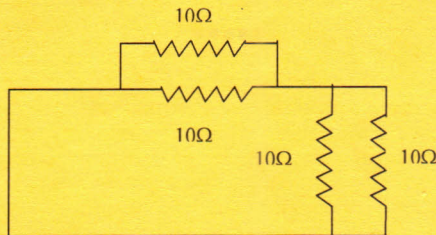
1. a) Using KVL find the currents in the branches:



b) Explain current division and voltage division rule.

(6+4=10)

2. a) Find the equivalent resistance of the following fig.



b) What is Ohm's law? Find the expression for specific resistance of a conductor.

(5+5=10)

3. a) Discuss the significance of Fermi level for intrinsic semiconductor material.
b) What is an ideal diode? Explain the formation of depletion layer.
(5+2+3=10)
4. a) Find the expressions for charge densities for P-type and N-type semiconductor.
b) What are breakdown devices? Explain two transistor analogy of SCR.
(5+2+3=10)
5. What is mobility? Derive the diode equation.
(2+8=10)
6. a) Derive the relationship among the current amplification factor for CB, CE and CC configuration.
b) Explain the input and output characteristics of PNP transistor in CB mode.
(5+5=10)
7. a) What is a FET? What are the advantages of FET over the conventional transistor?
b) Explain in brief the operation and construction of DEMOSFET.
(5+5=10)
8. a) Explain the construction and operation of UJT.
b) Explain JFET drain characteristics.
(5+5=10)

9. FET consists of a
- a) source
 - b) drain
 - c) gate
 - d) all of the above
10. In DE MOSFET, drain current flows when gate voltage is
- a) positive
 - b) negative
 - c) zero
 - d) all
11. The positive gate operation of an N-channel DE MOSFET is known as
- a) depletion mode
 - b) enhancement mode
 - c) E-only
 - d) normal
12. In an intrinsic semiconductor, Fermi level lies
- a) in the middle of conduction and valence bands.
 - b) near conduction band.
 - c) near valence band.
 - d) none of the above.
13. Which of the following atoms may be used as a P-type impurity?
- a) Arsenic
 - b) Boron
 - c) Phosphorous
 - d) Antimony
14. Avalanche breakdown in semiconductor occurs if
- a) forward current exceeds a certain value.
 - b) reverse bias exceeds a certain value.
 - c) forward bias exceeds a certain value.
 - d) the potential barrier is reduced to zero.
15. The most heavily doped region in a transistor is
- a) base
 - b) emitter
 - c) collector
 - d) both emitter and collector
16. In a symbol of transistor, the sign of arrow shows
- a) emitter
 - b) base
 - c) collector
 - d) both (a) and (c)
17. The transistor configuration producing highest output resistance is
- a) CC
 - b) CB
 - c) CE
 - d) none
18. When Ge crystal is doped with P atoms, it becomes
- a) N-type semiconductor
 - b) P-type semiconductor
 - c) an insulator
 - d) photo-transistor

19. The main factor which differentiates DEMOSFET from an E- only MOSFET is the absence of

- a) insulated gate
- b) electrons
- c) channel
- d) P-N junctions

20. Large energy gap is found in

- a) insulator
- b) conductor
- c) semiconductor
- d) all
